IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Norio KIMURA et al.

Serial No. 09/864,208

Filed May 25, 2001

SUBSTRATE POLISHING APPARATUS: AND SUBSTRATE POLISHING METHOD

Confirmation No. 1632

Commination No. 1032

Attorney Docket No. 2001-0660A

Group Art Unit 1763

Examiner Jeffrie R. Lund

MAIL STOP: AMENDMENT

AMENDMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In response to the Office Action of October 4, 2005, the period for response to which having been extended by two months to March 4, 2006, kindly amend the above-referenced U.S. patent application as follows:

THE COMMISSIONER IS AUTHORIZED TO CHARGE ANY DEFICIENCY IN THE FEES FOR THIS PAPER TO DEPOSIT ACCOUNT NO. 23-0975